



PRESS RELEASE

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Micronic receives orders exceeding 150 MSEK

Täby, Sweden, June 11, 2001 — Micronic Laser Systems AB (Stockholmsbörsen's Attract 40: MICR), is at the forefront in semiconductor and display laser pattern generators for the production of photomasks to the world wide electronic industries.

Micronic today announces that it has received two orders totally exceeding 150 MSEK. One order was placed by an Asian company, for an Omega6500 laser pattern generator for production of semiconductor photomasks. The other order was received from a Japanese company, for a LRS11000 multi beam laser pattern generator for production of advanced photomasks used in TFT-displays. The systems will be delivered during the third and fourth quarter 2001.

"These important orders from both the semiconductor and the display market demonstrate the competitiveness of our Omega products and that our display customers continue to invest in critical technology despite a weak end user market," says Sven Löfquist, Micronic's president and CEO.

About Micronic Laser Systems AB

Micronic Laser Systems is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as micro lithography. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components.

Micronic is located in Täby, north of Stockholm and at present has subsidiaries in the United States and Japan and a service office in Taiwan. Micronic's net sales for 2000 amounted to MSEK 704 (MSEK 213 in 1999) and the company has 323 employees. Micronic maintains a web site at: <http://www.micronic.se>